

Special Issue

IberSPEECH 2018: Speech and Language Technologies for Iberian Languages

Message from the Guest Editors

Following previous editions, IberSPEECH'2018 will be held in Barcelona, from 21 to 23 November 2018. The IberSPEECH event—the fourth of its kind using this name—brings together the X Jornadas en Tecnologías del Habla and the V Iberian SLTech Workshop events. The conference provides a platform for scientific and industrial discussion and exchange around Iberian languages, with the following main topics of interests:

- Speech technology and applications
- Human speech production, perception, and communication
- Natural language processing and applications
- Speech, language and multimodality
- Resources, standardization, and evaluation

Guest Editors

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Deadline for manuscript submissions

closed (14 July 2019)



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Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

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